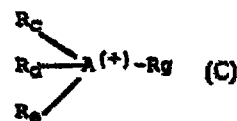
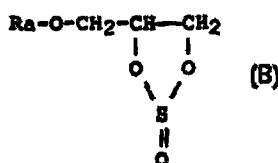
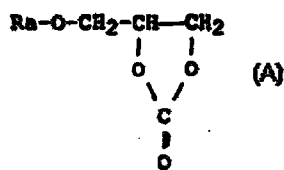
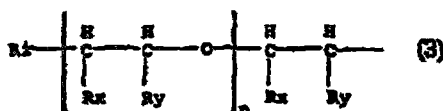
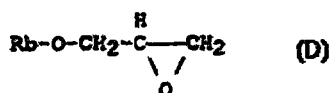




## INTERNATIONAL APPLICATION PUBLISHED UNDER THE PATENT COOPERATION TREATY (PCT)

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(54) Title: PROCESS FOR THE MANUFACTURE OF EPOXY COMPOUNDS



## (57) Abstract

Process for the manufacture of epoxy compounds of formula (D) wherein Rb represents a group selected from those of the formulae (1, 2 and 3) by reaction of a compound (A) or (B) with an alkylene oxide, in the presence of a catalyst, selected from the group of compounds containing at least one cation (C) in combination with a counter anion X<sup>-</sup> selected from halogen, acetate, phosphate or carboxylate or combinations thereof; manufacturing process for epoxy resins comprising at least the hereinbefore specified reaction step, and epoxy resins obtainable by said process, characterized by lower halogen content.